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### CONNECTION STRUCTURE

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#### Abstract

A connection structure is provided. The connection structure includes a first conductive pad, a first insulating layer, a second conductive pad, and a second insulating layer. The first insulating layer is disposed on the first conductive pad and includes a first through-hole exposing a first portion of the first conductive pad and another first through-hole exposing another first portion of the first conductive pad. The second conductive pad is disposed on the first insulating layer and electrically connected to the first conductive pad through the first through-hole and the another first through-hole. The second insulating layer is disposed on the second conductive pad and includes a plurality of second through-holes. The plurality of second through-holes expose a plurality of second portions of the second conductive pad. Moreover, in a top view, the plurality of second through-holes are disposed between the first through-hole and the another first through-hole.

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## **Background/Summary**

CROSS REFERENCE TO RELATED APPLICATIONS [0001] This application is a Continuation of pending U.S. patent application Ser. No. 18/063,714, filed Dec. 9, 2022 and entitled “CONNECTION STRUCTURE AND ELECTRONIC DEVICE”, which claims the benefit of China Application No. 202210017348.6, filed Jan. 7, 2022, the entirety of which are incorporated by reference herein.

### **BACKGROUND**

#### **Technical Field**

[0002] The present disclosure is related to a connection structure and an electronic device, and in particular it is related to a connection structure that can improve the peeling problem of the conductive pad and an electronic device including the connection structure.

#### **Description of the Related Art**

[0003] With the flourishing development of various electronic products, consumers have high expectations for the quality, function, or price of these products.

[0004] The circuit substrate and the electronic elements in an electronic device are usually electrically connected by connection structures (conductive pads) or other conductive elements. The connection structures are usually formed by stacking multiple layers of materials. However, the bondability of different material layers may affect the performance of the connection structure (e.g. it may affect electrical conductivity), thereby affecting the yield of the electronic device. Therefore, researchers in this industry are currently seeking to develop a structural design that can improve the performance of the connection structures.

### **SUMMARY**

[0005] In accordance with some embodiments of the present disclosure, a connection structure is provided. The connection structure includes a first conductive pad, a first insulating layer, a second conductive pad, and a second insulating layer. The first insulating layer is disposed on the first conductive pad and includes a first through-hole exposing a first portion of the first conductive pad and another first through-hole exposing another first portion of the first conductive pad. The second conductive pad is disposed on the first insulating layer and electrically connected to the first conductive pad through the first through-hole and the another first through-hole. The second insulating layer is disposed on the second conductive pad and includes a plurality of second through-holes. The plurality of second through-holes expose a plurality of second portions of the second conductive pad. Moreover, in a top view, the plurality of second through-holes are disposed between the first through-hole and the another first through-hole.

[0006] A detailed description is given in the following embodiments with reference to the accompanying drawings.

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## **Description**

### **BRIEF DESCRIPTION OF THE DRAWINGS**

[0007] The disclosure may be more fully understood by reading the subsequent detailed description and examples with references made to the accompanying drawings, wherein:

[0008] FIG. 1 is a top-view diagram of an electronic device in accordance with some embodiments of the present disclosure;

[0009] FIG. 2 is a top-view diagram of a connection structure in accordance with some embodiments of the present disclosure;

[0010] FIG. 3 is a cross-sectional diagram of a connection structure corresponding to the section line E1-F1 of FIG. 2 in accordance with some embodiments of the present disclosure;

[0011] FIG. 4 is a cross-sectional diagram of a connection structure corresponding to the section line A1-B1 of FIG. 2 in accordance with some embodiments of the present disclosure;

[0012] FIG. 5 is a cross-sectional diagram of a connection structure corresponding to the section line C1-D1 of FIG. 2 in accordance with some embodiments of the present disclosure;

[0013] FIG. 6 is a top-view diagram of a connection structure in accordance with some embodiments of the present disclosure;

[0014] FIG. 7 is a cross-sectional diagram of a connection structure corresponding to the section line A2-B2 of FIG. 6 in accordance with some embodiments of the present disclosure;

[0015] FIG. 8 is a top-view diagram of a connection structure in accordance with some embodiments of the present disclosure;

[0016] FIG. 9 is a cross-sectional diagram of a connection structure corresponding to the section line A3-B3 of FIG. 8 in accordance with some embodiments of the present disclosure;

[0017] FIG. 10 is a top-view diagram of a connection structure in accordance with some embodiments of the present disclosure;

[0018] FIG. 11 is a cross-sectional diagram of a connection structure corresponding to the section line A4-B4 of FIG. 10 in accordance with some embodiments of the present disclosure;

[0019] FIG. 12 is a top-view diagram of a connection structure in accordance with some embodiments of the present disclosure.

#### DETAILED DESCRIPTION

[0020] A connection structure and an electronic device according to the present disclosure are described in detail in the following description. It should be understood that in the following detailed description, for purposes of explanation, numerous specific details and embodiments are set forth in order to provide a thorough understanding of the present disclosure. The elements and configurations described in the following detailed description are set forth in order to clearly describe the present disclosure. These embodiments are used merely for the purpose of illustration, and the present disclosure is not limited thereto. In addition, different embodiments may use like and/or corresponding numerals to denote like and/or corresponding elements in order to clearly describe the present disclosure. However, the use of like and/or corresponding numerals of different embodiments does not suggest any correlation between different embodiments.

[0021] It should be understood that relative expressions may be used in the embodiments. For example, “lower”, “bottom”, “higher” or “top” are used to describe the position of one element relative to another. It should be appreciated that if a device is flipped upside down, an element that is “lower” will become an element that is “higher”. The present disclosure can be understood by referring to the following detailed description in connection with the accompanying drawings. The drawings are also regarded as a part of the description of the present disclosure. It should be understood that the drawings of the present disclosure may be not drawn to scale. In fact, the size of the elements may be arbitrarily enlarged or reduced to clearly represent the features of the present disclosure.

[0022] Furthermore, the expression “a first material layer is disposed on or over a second material layer” may indicate that the first material layer is in direct contact with the second material layer, or it may indicate that the first material layer is in indirect contact with the second material layer. In the situation where the first material layer is in indirect contact with the second material layer, there may be one or more intermediate layers between the first material layer and the second material layer. However, the expression “the first material layer is directly disposed on or over the second

material layer” means that the first material layer is in direct contact with the second material layer, and there is no intermediate element or layer between the first material layer and the second material layer.

[0023] Moreover, it should be understood that the ordinal numbers used in the specification and claims, such as the terms “first”, “second”, etc., are used to modify an element, which itself does not mean and represent that the element (or elements) has any previous ordinal number, and does not mean the order of a certain element and another element, or the order in the manufacturing method. The use of these ordinal numbers is to make an element with a certain name can be clearly distinguished from another element with the same name. Claims and the specification may not use the same terms. For example, the first element in the specification may refer to the second element in the claims.

[0024] In accordance with the embodiments of the present disclosure, regarding the terms such as “connected to”, “interconnected with”, etc. referring to bonding and connection, unless specifically defined, these terms mean that two structures are in direct contact or two structures are not in direct contact, and other structures are provided to be disposed between the two structures. The terms for bonding and connecting may also include the case where both structures are movable or both structures are fixed. In addition, the term “electrically connected to” or “electrically coupled to” may include any direct or indirect electrical connection means.

[0025] In the following descriptions, terms “about” and “substantially” typically mean  $\pm 10\%$  of the stated value, or typically  $\pm 5\%$  of the stated value, or typically  $\pm 3\%$  of the stated value, or typically  $\pm 2\%$  of the stated value, or typically  $\pm 1\%$  of the stated value or typically  $\pm 0.5\%$  of the stated value. The stated value of the present disclosure is an approximate value. That is, when there is no specific description, the stated value includes the meaning of “about” and “substantially”. Moreover, the expression “in a range from the first value to the second value” or “between the first value and the second value” means that the range includes the first value, the second value, and other values in between. In addition, certain errors may exist between any two values or directions used for comparison. If the first value is equal to the second value, it implies that there may be a 10% error between the first value and the second value; if the first direction is perpendicular to the second direction, the angle between the first direction and the second direction may be between 80 degrees and 100 degrees; if the first direction is parallel to the second direction, the angle between the first direction and the second direction may be between 0 degrees and 10 degrees.

[0026] Throughout the present disclosure and the appended claims, certain terms are used to refer to specific elements. Those skilled in the art should understand that electronic device manufacturers may refer to the same element with different names. The present disclosure does not intend to distinguish between elements that have the same function but different names. In the specification and claims, the terms “comprising”, “including”, “having” and the like are open-ended phrases, so they should be interpreted as “including but is not limited to . . .”. Therefore, when the terms “comprising”, “including” and/or “having” are used in the description of the present disclosure, they specify the corresponding features, regions, steps, operations and/or components, but do not exclude the existence of one or more corresponding features, regions, steps, operations and/or components.

[0027] It should be understood that in the following embodiments, without departing from the spirit of the present disclosure, the features in several different embodiments can be replaced, recombined, and mixed to complete another embodiment. The features between the various embodiments can be mixed and matched arbitrarily as long as they do not violate or conflict the spirit of the present disclosure.

[0028] Unless defined otherwise, all technical and scientific terms used herein have the same meaning as commonly understood by one of ordinary skill in the art to which this disclosure belongs. It should be appreciated that, in each case, the term, which is defined in a commonly used

dictionary, should be interpreted as having a meaning that conforms to the relative skills of the present disclosure and the background or the context of the present disclosure, and should not be interpreted in an idealized or overly formal manner unless so defined.

[0029] In accordance with the embodiments of the present disclosure, a connection structure is provided, which includes a conductive pad extending in a recessed structure, thereby increasing the contact area between the conductive pad and the underlying structure. The adhesion between the conductive pad and the underlying structure can be improved. The risk of peeling off between layers can be reduced.

[0030] The electronic device of the present disclosure may include a display device, a backlight device, a touch device, a sensing device, an antenna device, or a tiled device (a tiled device having any of the above functions or combined functions), but it is not limited thereto. The electronic device may include a bendable or flexible electronic device, but it is not limited thereto. The antenna device may be a liquid-crystal antenna device or a non-liquid-crystal antenna device. The sensing device may be a sensing device for sensing capacitance, light, heat or ultrasonic waves, but it is not limited thereto. The electronic device may include, for example, liquid crystal, quantum dot (QD), fluorescence, phosphor, another suitable material, or a combination thereof. In accordance with some embodiments, the electronic device may include an electronic unit, and the electronic unit may include passive elements and active elements, for example, capacitors, resistors, inductors, diodes, transistors, or a combination thereof, but they are not limited thereto. The diodes may include, for example, organic light-emitting diodes (OLEDs), micro light-emitting diodes (micro-LEDs, mini-LEDs) or quantum dot light-emitting diodes (QLEDs, QDLEDs), but they are not limited thereto. In accordance with some embodiments, the electronic device may include a panel and/or a backlight module, and the panel may include, for example, a liquid-crystal panel or another self-luminous panel, but it is not limited to. It should be understood that the electronic device of the present disclosure will be described below by taking a display device as an example, but the present disclosure is not limited thereto.

[0031] Refer to FIG. 1, which is a top-view diagram of an electronic device **1** in accordance with some embodiments of the present disclosure. For clarity, some elements of the electronic device **1** are omitted in the figures, and only some elements are schematically shown. In accordance with some embodiments, additional features may be added to the electronic device **1** described below. In accordance with some other embodiments, some features of the electronic device **1** described below may be replaced or omitted.

[0032] The electronic device **1** may include a substrate **102**. The substrate **102** may have an operation area RA and a peripheral area RB, and the peripheral area RB is adjacent to at least one side of the operation area RA. For example, the peripheral area RB may be disposed surrounding the operation area RA. In accordance with some embodiments, the operation area RA may be different according to the application of the electronic device **1**. For example, the operation area RA may include a display area, a detection area, a touch area, another suitable application area, or a combination thereof, and the peripheral area RB may be the area other than the operation area RA. The electronic device **1** may include an electronic unit **10U**, a driving unit (e.g., a driving unit **10T** and/or a driving unit **10T1**) and a connection structure **10C**. The electronic unit **10U**, the driving unit (e.g., the driving unit **10T** and/or the driving unit **10T1**) and the connection structure **10C** may be disposed on the substrate **102**. Specifically, the electronic unit **10U** may be disposed in the operation area RA, and the driving unit (e.g., the driving unit **10T** and/or the driving unit **10T1**) may be disposed in the peripheral area RB. The electronic unit **10U** and the driving unit **10T** may be electrically connected through the connection structure **10C**, and the driving unit **10T** may be used to control the electronic unit **10U**. The electronic unit **10U** and the driving unit **10T1** may be electrically connected through the connection structure **10C** and a wiring W1-1, and the driving unit **10T-1** may be used to control the electronic unit **10U**. Specifically, the driving unit **10T** and/or the driving unit **10T1** may have bonding pads (not illustrated), and the bonding pads of the driving

unit **10T** and/or the driving unit **10T1** may be respectively electrically connected to the connection structure **10C**. In accordance with some embodiments, the connection structure **10C** and the bonding pads (not illustrated) of the driving unit **10T** (and/or the driving unit **10T1**) may at least partially overlap in a normal direction Z of the substrate **102**. In accordance with some embodiments, the connection structure **10C** may be electrically connected to a wiring **W1** (or the wiring **W1-1**), and the wiring **W1** (or the wiring **W1-1**) may extend from the peripheral area RB to the operation area RA to be electrically connected to the electronic unit **10U**, but it is not limited thereto. In accordance with some embodiments, the wiring **W1** (or the wiring **W1-1**) may be a single-layer or composite-layer structure. In accordance with some embodiments, the wiring **W1** (or the wiring **W1-1**) may be, for example, the same layer as one of the conductive pads in the connection structure **10C**, but it is not limited thereto, which will be described in detail later.

[0033] In accordance with some embodiments, the electronic unit **10U** may be a pixel, and the pixel may include at least one thin-film transistor (TFT). The thin-film transistor may be used as a switching transistor, a driving transistor, and a reset transistor, or another suitable thin-film transistor, but it is not limited thereto. In accordance with some embodiments, the driving unit **10T** may include an integrated circuit (IC), a microchip, a flexible printed circuit (FPC) or another suitable driving element, but it is not limited thereto. In accordance with some embodiments, the driving unit **10T** may be disposed on the substrate **102** in the form of chip on film (COF), chip on glass (COG), etc., but it is not limited thereto. In accordance with some embodiments, the electronic device **1** may include a plurality of driving units **10T**, and the driving units **10T** may be located in the peripheral area RB and adjacent to the same side or different sides of the operation area RA. For example, in accordance with some embodiments of the present disclosure, as shown in FIG. 1, the operation area RA may have four sides and two driving units (e.g., driving unit **10T** and driving unit **10T1**), and the two driving units (e.g., driving unit **10T** and driving unit **10T1**) may be located in the peripheral area RB and adjacent to two sides of the operation area RA, but it is not limited thereto. In accordance with some embodiments, the driving unit **10T** and the driving unit **10T1** may be used for transmitting different signals (e.g., scanning signals or data signals), but it is not limited thereto. In other words, the wiring **W1** and the wiring **W1-1** may be used for transmitting different signals (e.g., scanning signals or data signals), but it is not limited thereto. It should be understood that the number or arrangement of the electronic units **10U** and the driving units are not limited to those shown in the figures. In accordance with some embodiments, a circuit structure (not illustrated) is disposed on the substrate **102** to serve as a driving substrate in the panel. In addition to the aforementioned electronic unit **10U**, driving unit (e.g., driving unit **10T** and/or driving unit **10T1**) and/or connection structure **10C**, the substrate **102** may be further provided with data lines (not illustrated) and scan lines (not illustrated), power lines (not illustrated), conductive pads, other circuits or components, etc., but it is not limited thereto. The substrate **102** may include a rigid substrate or a flexible substrate. In accordance with some embodiments, the material of the substrate **102** may include glass, quartz, ceramic, sapphire, polyimide (PI), polycarbonate (PC), polyethylene terephthalate (PET), another suitable material or a combination thereof, but it is not limited thereto.

[0034] Refer to FIG. 2 and FIG. 3. FIG. 2 is a top-view diagram of the connection structure **10C** in accordance with some embodiments of the present disclosure. FIG. 3 is a cross-sectional diagram of the connection structure **10C** corresponding to the section line E1-F1 of FIG. 2 in accordance with some embodiments of the present disclosure. In accordance with some embodiments, additional features may be added to the connection structure **10C** described below.

[0035] Refer to FIG. 2 and FIG. 3, the connection structure **10C** may include an insulating layer **104**, a first conductive pad **202**, a first insulating layer **106**, a second conductive pad **204**, a second insulating layer **108** and/or a third conductive pad **206**, but it is not limited thereto. Specifically, the insulating layer **104** may be disposed on the substrate **102**, the first conductive pad **202** may be disposed on the insulating layer **104**, the first insulating layer **106** may be disposed on the first

conductive pad **202**, the second conductive pad **204** may be disposed on the first insulating layer **106**, the second insulating layer **108** may be disposed on the second conductive pad **204**, and the third conductive pad **206** may be disposed on the second insulating layer **108**. In addition, another layer may be optionally formed between the above-mentioned layers.

[0036] In accordance with some embodiments, the insulating layer **104**, the first insulating layer **106** and/or the second insulating layer **108** may have a single-layer or multi-layer structure, and the materials of the multi-layers may be the same or different. In accordance with some embodiments, the materials of the insulating layer **104**, the first insulating layer **106** and/or the second insulating layer **108** may include inorganic materials or organic materials, but they are not limited thereto. For example, the materials of the insulating layer **104**, the first insulating layer **106** and/or the second insulating layer **108** may include silicon nitride, silicon oxide, silicon oxynitride, another suitable material or a combination thereof, but they are not limited thereto.

[0037] In accordance with some embodiments, the connection structure **10C** may be located in the peripheral area RB, and the connection structure **10C** may be electrically connected to the wiring W1 (or the wiring W1-1). For example, the first conductive pad **202** of the connection structure **10C** may be electrically connected to the wiring W1 (or the wiring W1-1), but it is not limited thereto. In accordance with some other embodiments (not illustrated), the connection structure **10C** and the wiring W1 may be electrically connected optionally by a via hole (not illustrated). In accordance with some embodiments, the first conductive pad **202** in the connection structure **10C** may have a long axis LA extending along a first direction Y and a short axis SA extending along a second direction X. In accordance with some embodiments, the first direction Y may be substantially perpendicular to and the second direction X. In accordance with some embodiments, the profile of the first conductive pad **202** may have an arc-shaped edge. It should be understood that the shape of the first conductive pad **202** is not limited to that shown in the figures, and the first conductive pad **202** may have another suitable shape.

[0038] In accordance with some embodiments, the first conductive pad **202** may include a conductive material, such as a metal material, but it is not limited thereto. The first conductive pad **202** may have a single-layer or multi-layer structure, and the materials of the multi-layer structure may be the same or different. The metal material may include copper (Cu), aluminum (Al), molybdenum (Mo), indium (In), tin (Sn), gold (Au), zinc (Zn), silver (Ag), titanium (Ti), lead (Pb), nickel (Ni), another suitable conductive material, or a combination thereof, but it is not limited thereto.

[0039] In accordance with some embodiments, the first insulating layer **106** may be disposed on the first conductive pad **202** and include a first through-hole **106v-1**, and the first through-hole **106v-1** may expose a portion of the first conductive pad **202**. The first insulating layer **106** may include a third through-hole **106v-2**, and the third through-hole **106v-2** may expose a portion of the first conductive pad **202**. In accordance with some embodiments, the first through-holes **106v-1** and the third through-holes **106v-2** may substantially be arranged along the first direction Y in which the long axis LA of the first conductive pad **202** extends. In accordance with some embodiments, the number of through-holes (including the first through-hole **106v-1** and the third through-hole **106v-2**) of the first insulating layer **106** may be more or less.

[0040] It should be understood that the shapes of the first through-holes **106v-1** and the third through-holes **106v-2** are not limited to those shown in the figures (e.g., oval shapes). In accordance with different embodiments, the first through-holes **106v-1** and the third through-hole **106v-2** may have another suitable shape (e.g., a circular shape or a shape with a curved edge). Furthermore, the shape (and/or size) of the first through-hole **106v-1** may be the same as or different from the shape (and/or size) of the third through-hole **106v-2**.

[0041] In accordance with some embodiments, the second conductive pad **204** may be disposed on the first insulating layer **106** and electrically connected to the first conductive pad **202** through the first through-hole **106v-1**. Specifically, the second conductive pad **204** may be disposed on the first

insulating layer **106** and filled in the first through-hole **106v-1**, so that the second conductive pad **204** is in contact with and electrically connected to the first conductive pad **202** that is exposed by the first through-hole **106v-1**, but it is not limited thereto. In accordance with some embodiments, the second conductive pad **204** may be electrically connected to the first conductive pad **202** through the third through-hole **106v-2**. Specifically, the second conductive pad **204** may be filled in the third through-hole **106v-2**, so that the second conductive pad **204** is in contact with and electrically connected to the first conductive pad **202** that is exposed by the third through-hole **106v-2**.

[0042] As shown in FIG. 3, in accordance with some embodiments, the first conductive pad **202** may include two contact portions (e.g., contact portion CT-1 and contact portion CT-2), and the second conductive pad **204** may be in contact with and electrically connected to one of the two contact portions through the first through-hole **106v-1**, and the second conductive pad **204** may be in contact with and electrically connected to the other of the two contact portions through the third through-hole **106v-2**. In detail, the second conductive pad **204** may be in contact with and electrically connected to the contact portion CT-1 through the first through-hole **106v-1**, and the second conductive pad **204** may be in contact with and electrically connected to the contact portion CT-2 through the third through-hole **106v-2**. As mentioned above, the first conductive pad **202** has the long axis LA extending along the first direction Y, and the two contact portions (e.g., the contact portion CT-1 and the contact portion CT-2) may substantially be arranged along the first direction Y, but it is not limited thereto. In other words, the first through-holes **106v-1** and the third through-holes **106v-2** may substantially be arranged along the first direction Y.

[0043] In accordance with some embodiments, the second conductive pad **204** may include a conductive material, such as a metal material, but it is not limited thereto. The second conductive pad **204** may have a single-layer or multi-layer structure, and the materials of the multi-layers may be the same or different. The materials of the first conductive pad **202** and the second conductive pad **204** may be the same or different. The number of layers of the first conductive pad **202** and the second conductive pad **204** may be the same or different.

[0044] As shown in FIG. 3, in accordance with some embodiments, the second insulating layer **108** may be disposed on the second conductive pad **204** and include a second through-hole **108v** and a first recessed portion **108r-1**, and the first recessed portion **108r-1** may overlap the first through-hole **106v** in the normal direction Z of the substrate **102**. In accordance with some embodiments, the second through-hole **108v** of the second insulating layer **108** may expose a portion of the second conductive pad **204**. In accordance with some embodiments, the second insulating layer **108** may include a second recessed portion **108r-2**, and the second recessed portion **108r-2** may overlap the third through-hole **106v-2** in the normal direction Z of the substrate **102**. In accordance with some embodiments, in the normal direction Z of the substrate **102**, the two contact portions (e.g., the contact portion CT-1 and the contact portion CT-2) do not overlap the second through-hole **108v**.

[0045] In accordance with some embodiments, in the cross section of the connection structure **10C**, the upper surface of the first recessed portion **108r-1** or the upper surface of the second recessed portion **108r-2** may have an arc-shaped edge, but it is not limited thereto. In accordance with some embodiments, in the normal direction Z of the substrate **102**, the profile or size of the second through-hole **108v** may be different from that of the first through-hole **106v-1** or the third through-hole **106v-2**. In accordance with some embodiments, the number of through-holes of the first insulating layer **106** is the same as or different from the number of through-holes of the second insulating layer **108**.

[0046] In accordance with the embodiments of the present disclosure, in the cross section of the connection structure **10C**, two ends of the upper surface of the first conductive pad **202** exposed by the first through-hole **106v-1** define a virtual line La and a virtual line Lb respectively, and the portion of the second insulating layer **108** located in the range of the virtual line La and the virtual



line Lb may be defined as the first recessed portion **108r-1**. Furthermore, the virtual line La and the virtual line Lb may extend substantially along the normal direction Z of the substrate **102**. Similarly, in the cross section of the connection structure **10C**, two ends of the upper surface of the first conductive pad **202** exposed by the third through-hole **106v-2** define a virtual line Lc and a virtual line Ld respectively, and the portion of the second insulating layer **108** located in the range of the virtual line Lc and the virtual line Ld may be defined as the second recessed portion **108r-2**. Furthermore, the aforementioned virtual line Lc and virtual line Ld may extend substantially along the normal direction Z of the substrate **102**.

[0047] As mentioned above, FIG. **3** corresponds to the cross-sectional diagram of the connection structure **10C** along the section line E1-F1 of FIG. **2**, and the section line E1-F1 may be the section line extending along the first direction Y (i.e. the extending direction of the long axis LA of the first conductive pad **202**). As shown in FIG. **3**, the first recessed portion **108r-1** may have a depth D1, and the second through-hole **108v** may have a depth D2. The depth D1 of the first recessed portion **108r-1** may be different from the depth D2 of the second through-hole **108v**, but it is not limited thereto. In accordance with some embodiments, the depth D1 of the first recessed portion **108r-1** may be greater than the depth D2 of the second through-hole **108v**.

[0048] Referring to FIG. **3**, the definition of the depth D1 of the first recessed portion **108r-1** is as follows. First, the virtual line La and the virtual line Lb may intersect with the surface of the second insulating layer **108** (i.e. the surface **108s-1** of the first recessed portion **108r**) at two points (not labeled), and a virtual line Lx may be obtained by connecting the two points. Next, the depth D1 of the first recessed portion **108r-1** may be defined as the maximum distance between the virtual line Lx and the surface **108s-1** of the first recessed portion **108r-1** in the normal direction Z of the substrate **102**.

[0049] In addition, the definition of the depth D2 of the second through-hole **108v** is as follows. First, find the two ends (not labeled) of the upper surface of the second conductive pad **204** exposed by the second through-hole **108v**. Next, find virtual lines that pass through the two ends and extend substantially along the normal direction Z of the substrate **102** respectively, such as a virtual line Le and a virtual line Lf. Next, in the direction of section line of the cross-sectional diagram (e.g., the first direction Y), two points (not labeled) intersecting with the second insulating layer **108** may be obtained respectively from the virtual line Le and the virtual line Lf about 1 micrometer ( $\mu\text{m}$ ) the direction away from the second through-hole **108v**, and a virtual line Ly may be obtained by connecting the two points. Next, the depth D2 of the second through-hole **108v** may be defined as the maximum distance between the virtual line Ly and the upper surface of the second conductive pad **204** that is exposed by the second through-hole **108v** in the normal direction Z of the substrate **102**.

[0050] Similarly, the second recessed portion **108r-2** may have a depth D1-1, and the depth D1-1 of the second recessed portion **108r-2** may be different from the depth D2 of the second through-hole **108v**, but it is not limited thereto. Furthermore, the depth D1 of the first recessed portion **108r-1** may be the same as or different from the depth D1-1 of the second recessed portion **108r-2**. The depth D1-1 of the second recessed portion **108r-2** may be defined as follows. First, the virtual line Lc and the virtual line Ld may intersect with the surface of the second insulating layer **108** (i.e. the surface **108s-2** of the second recessed portion **108r-2**) at two points (not labeled), and a virtual line Lx' may be obtained by connecting the two points. Next, the depth D1-1 of the second recessed portion **108r-2** may be defined as the maximum distance between the virtual line Lx' and the surface **108s-2** of the second recessed portion **108r-2** in the normal direction Z of the substrate **102**.

[0051] In accordance with some embodiments, the depth D1 of the first recessed portion **108r-1** may be between 250 nanometers (nm) and 900 nm (i.e.  $250\text{ nm} \leq \text{depth D1} \leq 900\text{ nm}$ ), or between 350 nm and 850 nm, for example, 500 nm, 600 nm, 700 nm or 800 nm, but it is not limited thereto. In accordance with some embodiments, the depth D2 of the second through-hole **108v** may be between 50 nm and 800 nm (i.e.  $50\text{ nm} \leq \text{depth D2} \leq 800\text{ nm}$ ), or between 60 nm and 750 nm, for

example, 100 nm, 200 nm, 300 nm, 400 nm, 500 nm, 600 nm or 700 nm, but it is not limited thereto. In accordance with some embodiments, the depth D1-1 of the second recessed portion **108r-2** may be between 250 nanometers (nm) and 900 nm (i.e.  $250\text{ nm} \leq \text{depth D1-1} \leq 900\text{ nm}$ ), or between 350 nm and 850 nm, for example, 500 nm, 600 nm, 700 nm or 800 nm, but it is not limited thereto.

[0052] It should be noted that, as shown in FIG. 3, the depth D1 of the first recessed portion **108r-1**, the depth D2 of the second recessed portion **108r-2**, and the depth D1-1 of the second recessed portion **108r-2** may be measured in the same cross-sectional diagram, but it is not limited thereto. FIG. 3 of the present disclosure is a cross-sectional diagram of the connection structure **10C** along the section line E1-F1 (extending substantially along the first direction X) in FIG. 2, but it is not limited thereto. The depth D1, the depth D2 and the depth D1-1 may be measured in the same cross-sectional diagram, but the extending direction of the section line of the cross-sectional diagram may be another suitable direction other than the first direction X.

[0053] It should be noted that although the depth D1, the depth D2, and the depth D1-1 shown in FIG. 3 are compared by the measurement results in the same cross-sectional diagram, but it is not limited thereto. In other cases, the depth D1, the depth D2 and the depth D1-1 may also be measured in different cross-sectional diagrams, but the directions of the section lines of different cross-sectional diagrams should extend along the same direction (for example, the first direction Y, the second direction X or another suitable direction), as shown in FIG. 4 and FIG. 5.

[0054] FIG. 4 is a cross-sectional diagram of the connection structure **10C** corresponding to the section line A1-B1 of FIG. 2 in accordance with some embodiments of the present disclosure. FIG. 5 is a cross-sectional diagram of the connection structure **10C** corresponding to the section line C1-D1 of FIG. 2 in accordance with some embodiments of the present disclosure. FIG. 4 shows the cross-sectional diagram including the first through-hole **106v-1**, and FIG. 5 shows the cross-sectional diagram including the second through-hole **108v**. As shown in FIG. 4 and FIG. 5, the depth D1 of the first recessed portion **108r-1** and the depth D2 of the second recessed portion **108r-2** may be measured under different cross-sectional diagrams, but the extending directions of the section lines of the different cross-sectional diagrams both extend along, for example, the first direction Y. In FIG. 4 and FIG. 5, the definitions of the depth D1 of the first recessed portion **108r-1** and the depth D2 of the second recessed portion **108r-2** may refer to the above definitions, and the design relationship between the depth D1 and the depth D2 may also refer to the above descriptions.

[0055] It should be understood that, in accordance with the embodiments of the present disclosure, an optical microscope (OM), a scanning electron microscope (SEM), a film thickness profiler ( $\alpha$ -step), an ellipsometer, or other suitable methods can be used to measure the depth, thickness, width or height of an element, or the distance or spacing between elements. Specifically, in accordance with some embodiments, a scanning electron microscope can be used to obtain a cross-sectional image including the element to be measured, and the depth, thickness, width or height of an element, or the distance or spacing between elements in the image can be measured.

[0056] In addition, as shown in FIG. 3, the third conductive pad **206** may be disposed on the second insulating layer **108** and electrically connected to the second conductive pad **204** through the second through-hole **108v**, and the third conductive pad **206** may extend on the surface **108s-1** of the first recessed portion **108r-1** and/or the surface **108s-2** of the second recessed portion **108r-2**, but it is not limited thereto. In other words, the third conductive pad **206** may be disposed on the surface **108s-1** of the first recessed portion **108r-1** and/or the surface **108s-2** of the second recessed portion **108r-2**. Moreover, the third conductive pad **206** may be disposed on the second insulating layer **108** and in the second through-hole **108v**, so that the third conductive pad **206** may be in contact with and electrically connected to the second conductive pad **204** exposed by the second through-hole **108v**. In accordance with some embodiments, in the normal direction Z of the substrate **102**, the second through-hole **108v** does not overlap the first recessed portion **108r-1** and

the second recessed portion **108r-2**.

[0057] In accordance with some embodiments, the third conductive pad **206** may include a transparent conductive material, for example, may include indium tin oxide (ITO), tin oxide (SnO), zinc oxide (ZnO), indium zinc oxide (IZO), indium gallium zinc oxide (IGZO), indium tin zinc oxide (ITZO), antimony tin oxide (ATO), antimony zinc oxide (AZO), another suitable transparent conductive material or a combination thereof, but it is not limited thereto. The third conductive pad **206** may have a single-layer or multi-layer structure, and the materials of the multi-layers may be the same or different.

[0058] In accordance with some embodiments, the insulating layer **104**, the first insulating layer **106** and/or the second insulating layer **108** may be formed by a coating process, a chemical vapor deposition process, a physical vapor deposition process, an evaporation process, a sputtering process, another suitable process, or a combination thereof. Furthermore, the first through-hole **106v-1**, the third through-hole **106v-2** and/or the second through-hole **108v** may be formed by one or more photolithography processes and/or etching processes.

[0059] As mentioned above, the third conductive pad **206** may cover the second conductive pad **204** exposed by the second through-hole **108v** to reduce the risk of oxidation of the second conductive pad **204** when exposed to the air. It should be noted that, in accordance with the embodiments of the present disclosure, in addition to covering the second conductive pad **204**, the third conductive pad **206** further extends onto the first recessed portion **108r-1** and/or the second recessed portion **108r-2** of the second insulating layer **108** as described above. In accordance with some embodiments, the third conductive pad **206** may have an irregular-shaped surface. By forming the third conductive pad **206** on the structure with the height difference as described above (e.g., the second insulating layer **108** having the first recessed portion **108r-1** and/or the second recessed portion **108r-2**), the contact area between the third conductive pad **206** and the underlying structure (e.g., the second insulating layer **108**) can be increased, and the chance of peeling off of the third conductive pad **206** can be reduced.

[0060] In accordance with some embodiments, the first recessed portion **108r-1** and the second recessed portion **108r-2** may be located at two ends of the first conductive pad **202**. For example, the first recessed portion **108r-1** and the second recessed portion **108r-2** may be arranged along the first direction Y, and the first direction Y may be the extending direction of the long axis LA of the first conductive pad **202**, but it is not limited thereto. With the above structural design, the risk of peeling off the third conductive pad **206** from the end portion of the first conductive pad **202** can be reduced.

[0061] Moreover, as shown in FIG. 3 and FIG. 4, at the position corresponding to the first through-hole **106v-1** (i.e. range of projection of the first through-hole **106v-1** to the substrate **102**), the first conductive pad **202** may have the contact portion CT-1, and the position of the contact portion CT-1 may overlap the first through-hole **106v-1**, so that the first conductive pad **202** may be in contact or electrically connected to the second conductive pad **204** through the first through-hole **106v-1**. Similarly, at the position corresponding to the third through-hole **106v-2** (i.e. the range of projection of the third through-hole **106v-2** to the substrate **102**), the first conductive pad **202** may have the contact portion CT-2, and the position of the contact portion CT-2 may overlap the third through-hole **106v-2**, so that the first conductive pad **202** may be in contact or electrically connected to the second conductive pad **204** through the third through-hole **106v-2**.

[0062] In addition, as shown in FIG. 3 and FIG. 5, at the position corresponding to the second through-hole **108v** (i.e. the range of projection of the second through-hole **108v** to the substrate **102**), a part of the first insulating layer **106** may be disposed between the first conductive pad **202** and the second conductive pad **204**, so that the first conductive pad **202** corresponding to the position of the second through-hole **108v** is not in contact with the second conductive pad **204**. In addition, the third conductive pad **206** may be in contact or electrically connected to the second conductive pad **204** through the second through-hole **108v**.

[0063] As shown in FIG. 4 and FIG. 5, in accordance with some embodiments, the first conductive pad **202** may have an edge **202e** and an edge **202e1** in the second direction X, and the edge **202e** and the edge **202e1** may be opposite to each other. In accordance with some embodiments, the second conductive pad **204** may have an edge **204e** and an edge **204e1** in the second direction X, and the edge **204e** and the edge **204e1** may be opposite to each other. In accordance with some embodiments, the edge **202e** may or may not extend beyond the edge **204e** of the second conductive pad **204** in the second direction X. In accordance with some embodiments, the edge **202e1** may or may not extend beyond edge **204e1** in the second direction X. In accordance with some embodiments, the relative relation between the edge **204e** and the edge **202e** in the second direction X (e.g., extend beyond or not) may be the same as or different from the relative relation between the edge **204e1** and the edge **202e1** in the second direction X (e.g., extend beyond or not). For example, as shown in FIG. 4, in the second direction X, the edge **202e** may be substantially aligned with the edge **204e**, and the edge **202e** may exceed the edge **204e**, but it is not limited thereto. In accordance with some embodiments, the edge **202e**, edge **204e**, edge **202e1** and/or edge **204e1** may have arc-shaped edges.

[0064] As described above, the first conductive pad **202** may have the short axis SA extending along the second direction X, and the third conductive pad **206** may extend beyond the edge **204e** (or the edge **204e1**) of the second conductive pad **204** in the second direction X. In accordance with some embodiments, the third conductive pad **206** may extend beyond the edge **202e** (or the edge **202e1**) of the first conductive pad **202** in the second direction X. In other words, in the second direction X, the third conductive pad **206** may cover the edge **202e** (or the edge **202e1**) of the first conductive pad **202** and/or the edge **204e** (or the edge **204e1**) of the second conductive pad **204**, but it is not limited thereto. With the above configuration, the adhesion of the third conductive pad **206** at the edge of the short axis SA of the first conductive pad **202** can be increased, and the risk of peeling off of the third conductive pad **206** can also be reduced.

[0065] In accordance with some other embodiments (not illustrated), in the first direction Y, the third conductive pad **206** may extend beyond the edge (not labeled) of the first conductive pad **202** and/or the edge (not labeled) of the second conductive pad **204**, but it is not limited thereto. Therefore, the adhesion of the third conductive pad **206** at the edge of the long axis LA of the first conductive pad **202** can be increased, and the risk of peeling off of the third conductive pad **206** can also be reduced. In accordance with some other embodiments (not illustrated), the third conductive pad **20** may extend beyond the edge (not labeled) of the second conductive pad **204** in other directions (e.g., directions other than the first direction Y or the second direction X), so as to increase the adhesion of the third conductive pad **206** and also reduces the risk of peeling off of the third conductive pad **206**.

[0066] Next, refer to FIG. 6 and FIG. 7. FIG. 6 is a top-view diagram of a connection structure **10C-1** in accordance with some other embodiments of the present disclosure. FIG. 7 is a cross-sectional diagram of the connection structure **10C-1** corresponding to the section line A2-B2 of FIG. 6 in accordance with some embodiments of the present disclosure. It should be understood that the same or similar components or elements in above and below contexts are represented by the same or similar reference numerals. The materials, manufacturing methods and functions of these components or elements are the same or similar to those described above, and thus will not be repeated herein.

[0067] In accordance with this embodiment, in addition to the first through-hole **106v-1** and the third through-hole **106v-2**, the first insulating layer **106** may further include other through-holes (e.g., the first through-hole **106v-1'** and/or the third through-hole **106v-2'**). That is, the first insulating layer **106** corresponding to the two ends of the first conductive pad **202** may each have a plurality of through-holes, such as two through-holes, but it is not limited thereto. In accordance with this embodiment, the first through-hole **106v-1** and the first through-hole **106v-1'** may correspond to one end of the first conductive pad **202**, and the first through-hole **106v-1** and the

first through-hole **106v-1'** may be arranged substantially along the second direction X, but it is not limited thereto. In accordance with this embodiment, the third through-hole **106v-2** and the third through-hole **106v-2'** may correspond to the other end of the first conductive pad **202**, and the third through-hole **106v-2** and the third through-hole **106v-2'** may be arranged substantially along the second direction X, but it is not limited thereto. In accordance with other embodiments, the numbers of through-holes of the first insulating layer **106** corresponding to the two ends of the first conductive pad **202** may be the same or different. Furthermore, in accordance with this embodiment, the second insulating layer **108** may include a plurality of second through-holes **108v**. In accordance with this embodiment, the plurality of second through-holes **108v** of the second insulating layer **108** may be arranged substantially along the first direction Y, but it is not limited thereto. In accordance with other embodiments (not illustrated), the plurality of second through-holes **108v** of the second insulating layer **108** is not limited to only one row. It should be understood that the numbers of the through-holes of the first insulating layer **106** and the second insulating layer **108** are not limited to those shown in the figures. According to different embodiments, the first insulating layer **106** and the second insulating layer **108** may have other suitable numbers of through-holes. Furthermore, the number of through-holes of the first insulating layer **106** corresponding to the two ends of the long axis LA of the first conductive pad **202** may be the same or different. In accordance with this embodiment, the size of the second through-hole **108v** of the second insulating layer **108** may be larger than the size of the through-hole (e.g., the first through-hole **106v-1'** and/or the third through-hole **106v-2'**) of the first insulating layer **106**, but it is not limited thereto. In accordance with this embodiment, the profile of the second through-hole **108v** of the second insulating layer **108** may have an arc-shaped edge, but it is not limited thereto. In accordance with this embodiment, the profile of the through-holes of the first insulating layer **106** may have an arc-shaped, but it is not limited thereto. In accordance with this embodiment, the profile of the second through-hole **108v** may have different widths in the first direction Y and the second direction X, but it is not limited thereto. For example, the width of the profile of the second through-hole **108v** in the first direction Y may be greater than the width in the second direction X, but it is not limited thereto. In accordance with other embodiments (not illustrated), the width of the profile of the second through-hole **108v** in the first direction Y and the second direction X may be substantially the same. That is, the profile of the second through-hole **108v** may be substantially circular, but it is not limited thereto.

[0068] As shown in FIG. 7, in the second direction X, the first through-hole **106v-1** and the first through-hole **106v-1'** may be separated, for example, by a portion P of the first insulating layer **106**. The second conductive pad **204** may be disposed on the first insulating layer **106** and electrically connected to one end of the first conductive pad **202** through the first through-hole **106v-1** and the first through-hole **106v-1'**. Similarly, the second conductive pad **204** may also be electrically connected to the other end of the first conductive pad **202** through the third through-hole **106v-2** and the third through-hole **106v-2'**. As shown in FIG. 7, the first conductive pad **202** may include a contact portion CT-1 and a contact portion CT-1', and the second conductive pad **204** may be in contact with and electrically connected to the contact portion CT-1 through the first through-hole **106v-1**, and the second conductive pad **204** may be in contact with and electrically connected to the contact portion CT-1' through the first through-hole **106v-1'**. In accordance with this embodiment, the first through-holes **106v-1** and the first through-holes **106v-1'** may be arranged along the second direction X. In accordance with some embodiments, in the second direction X, a width PW of the portion P of the first insulating layer **106** located between the first through-hole **106v-1** and the first through-hole **106v-1'** may be smaller than or equal to a width OW1 of the first through-hole **106v-1** or a width OW2 of the first through-hole **106v-1'**, but it is not limited thereto. The width PW of the portion P of the first insulating layer **106** can be defined as the width of the surface of the portion P in contact with the first conductive pad **202** in a cross-section. The width OW1 of the first through-hole **106v-1** substantially may be the width of the surface of the first conductive pad **202** exposed

by the first through-hole **106v-1**. The width OW2 of the first through-hole **106v-1'** substantially may be the width of the surface of the first conductive pad **202** exposed by the first through-hole **106v-1'**. In accordance with some embodiments, the portion P of the first insulating layer **106** between the first through-hole **106v-1** and the first through-hole **106v-1'** may have an arc-shaped surface.

[0069] In accordance with this embodiment, at one end of the short axis SA of the first conductive pad **202**, the edge **204e** of the second conductive pad **204** may extend beyond the edge **202e** of the first conductive pad **202**. At the other end of the short axis SA of the first conductive pad **202**, the edge **202e1** of the first conductive pad **202** may extend beyond the edge **204e1** of the second conductive pad **204**, but it is not limited thereto.

[0070] Furthermore, the second insulating layer **108** may include a first recessed portion **108r-1** and a first recessed portion **108r-1'**. In the normal direction Z of the substrate **102**, the first recessed portion **108r-1** may overlap the first through-hole **106v-1**, and the first recessed portion **108r-1'** may overlap the first through-hole **106v-1'**. The first recessed portion **108r-1** and the first recessed portion **108r-1'** may be arranged along the second direction X (i.e. the extending direction X of the short axis SA of the first conductive pad **202**). As shown in FIG. 7, the first recessed portion **108r-1** may have a depth D1, the first recessed portion **108r-1'** may have a depth D1', and the depth D1 of the first recessed portion **108r-1** may be the same as or different from the depth D1' of the first recessed portion **108r-1'**. The definitions of the first recessed portion **108r-1'** and the depth D1' are similar to the definitions of the aforementioned first recessed portion **108r-1** and the depth D1, and thus are not repeated here.

[0071] The third conductive pad **206** may extend on the surface **108s-1** of the first recessed portion **108r-1** and the surface **108s-1'** of the first recessed portion **108r-1'**. In accordance with this embodiment, the third conductive pad **206** not only may extend onto the first recessed portion **108r-1** of the second insulating layer **108**, but also may extend onto the first recessed portion **108r-1'** of the second insulating layer **108**. By arranging a plurality of recess portions in the second insulating layer **108** and extending the third conductive pad **206** to these recess portions, the contact area between the third conductive pad **206** and the underlying structure (e.g., the second insulating layer **108**) can be increased, and the adhesion of the third conductive pad **206** to the underlying structure can be increased. Therefore, the risk of peeling off of the third conductive pad **206** can be reduced. Similarly, the second insulating layer **108** may include two second recess portions (not illustrated), and in the normal direction Z of the substrate **102**, the two recess portions (not illustrated) may overlap the second through-holes **106v-2** and the second through-hole **106v-2'**, respectively. Similarly, the third conductive pad **206** may extend on the surfaces (not illustrated) of the two second recess portions (not illustrated).

[0072] Next, refer to FIG. 8 and FIG. 9. FIG. 8 is a top-view diagram of a connection structure **10C-2** in accordance with some other embodiments of the present disclosure. FIG. 9 is a cross-sectional diagram of the connection structure **10C-2** corresponding to the section line A3-B3 of FIG. 8 in accordance with some embodiments of the present disclosure.

[0073] The first insulating layer **106** of the connection structure **10C-2** may include a first through-hole **106v-1** and a third through-hole **106v-2**, and the second insulating layer **108** may include a plurality of second through-holes **108v** along the first direction X. In accordance with this embodiment, the size (e.g., area) of the first through-hole **106v-1** may be larger than the size (e.g., area) of the second through-hole **108v**, but it is not limited thereto. In accordance with this embodiment, the size (e.g., area) of the third through-hole **106v-2** may be larger than the size (e.g., area) of the second through-hole **108v**, but it is not limited thereto. In accordance with this embodiment, the number of through-holes of the first insulating layer **106** may be less than the number of through-holes of the second insulating layer **108** (e.g., the second through-holes **108v**). In accordance with this embodiment, the width of the profile of the second through-hole **108v** in the first direction Y and the second direction X may be substantially the same, but it is not limited

thereto. As shown in FIG. 9, in accordance with this embodiment, the second conductive pad **204** may have a multi-layer structure, for example, including a sub-layer **204a**, a sub-layer **204b** and/or a sub-layer **204c**, but it is not limited thereto. The materials of sublayer **204a**, sublayer **204b**, and/or sublayer **204c** may be the same or different. In accordance with some embodiments, the materials of the sub-layer **204a**, the sub-layer **204b**, and the sub-layer **204c** may be molybdenum, aluminum, and molybdenum, respectively, but they are not limited thereto. In accordance with some embodiments (not illustrated), the first conductive pad **202** may have a multi-layer structure. In accordance with some embodiments, in the normal direction Z of the substrate **102**, the thickness of the second conductive pad **204** may be the same as or different from the thickness of the first conductive pad **202**. In accordance with some embodiments, in the normal direction Z of the substrate **102**, the thickness of the second conductive pad **204** may be greater than the thickness of the first conductive pad **202**. In accordance with some embodiments, in the normal direction Z of the substrate **102**, the thickness of the second conductive pad **204** may be smaller than the thickness of the first conductive pad **202**. The thickness of the first conductive pad **202** or the thickness of the second conductive pad **204** can be measured along a virtual line L1 respectively, and the virtual line L1 is parallel to the normal direction Z of the substrate **102** and passes through the first through-hole **106v-1**.

[0074] In accordance with some embodiments, in the normal direction Z of the substrate **102**, the thickness of the first insulating layer **106** may be the same as or different from the thickness of the second insulating layer **108**. In accordance with some embodiments, in the normal direction Z of the substrate **102**, the thickness of the first insulating layer **106** may be greater than the thickness of the second insulating layer **108**. In accordance with some embodiments (not illustrated), in the normal direction Z of the substrate **102**, the thickness of the first insulating layer **106** may be smaller than the thickness of the second insulating layer **108**. The thickness of the first insulating layer **106** and the second insulating layer **108** can be measured along a virtual line L2. The virtual line L2 is parallel to the normal direction Z of the substrate **102** and does not pass through the first conductive pad **202** and the second conductive pad **204**.

[0075] In accordance with this embodiment, at one end of the short axis SA of the first conductive pad **202**, the edge **204e** of the second conductive pad **204** may extend beyond the edge **202e** of the first conductive pad **202**. At the other end of the short axis SA of the **202** of the first conductive pad **202**, the edge **202e1** of the first conductive pad **202** may extend beyond the edge **204e1** of the second conductive pad **204**, but it is not limited thereto.

[0076] As shown in FIG. 9, the second insulating layer **108** may have a side recessed portion **108sr**, and the side recessed portion **108sr** may extend beyond the edge (e.g., the edge **204e** or the edge **204e1**) of the second conductive pad **204** in the second direction X (i.e. the extending direction of the short axis SA of the first conductive pad **202**). In addition, the third conductive pad **206** may extend on a surface **108sr-s** of the side recessed portion **108sr**. The definition of the side recessed portion **108sr** is as follows. First, in a cross-section, a virtual line Lg is obtained that passes through the edge of the first conductive pad **202** (e.g., the edge **202e** or the edge **202e1**) and extends substantially along the normal direction Z of the substrate **102**. The virtual line Lg and the surface of the second insulating layer **108** intersect at an intersection point CP, and the intersection point CP is defined as the starting end of the side recessed portion **108sr**. In addition, under the same cross-section, the outer edge of the third conductive pad **206** is projected onto the second insulating layer **108** to obtain a side end point SP, and a virtual line Lh that passes through the side end point SP and extends substantially along the normal direction Z of the substrate **102** is obtained. The portion of the second insulating layer **108** located within the range of the virtual line Lg and the virtual line Lh is defined as the side recessed portion **108sr**. Moreover, the side recessed portion **108sr** may have a surface **108sr-s** that is away from the substrate **102**. In other words, the intersection point CP may be the starting point of the surface **108sr-s** of the side recessed portion **108sr**, and the side end point SP may be the end point of the surface **108sr-s** of the side recessed

portion **108sr**. In accordance with some embodiments, the surfaces **108sr-s** of the side recessed portion **108sr** may have a stepped profile, but it is not limited thereto. In accordance with some embodiments, the surfaces **108sr-s** of the side recessed portion **108sr** may have a wavy or irregular profile, but it is not limited thereto.

[0077] In accordance with some embodiments, the side recessed portion **108sr** may have a depth **D3**, and the depth **D3** of the side recessed portion **108sr** may be greater than the depth **D1** of the first recessed portion **108r-1**. The definition of the depth **D1** of the first recessed portion **108r-1** may refer to the above. The depth **D3** of the side recessed portion **108sr** is defined as follows. First, a virtual line **Lz** that passes through the above-mentioned intersection point **CP** and extend substantially perpendicular to the normal direction **Z** of the substrate **102** is obtained. Next, in the normal direction **Z** of the substrate **102**, the distance between the virtual line **Lz** and the side end point **SP** is defined as the depth **D3**.

[0078] In accordance with some implementations, the depth **D3** of the side recessed portion **108sr** may be between 500 nm and 1200 nm (i.e.  $500\text{ nm} \leq \text{depth D3} \leq 1200\text{ nm}$ ), or between 550 nm and 1100 nm, for example, 600 nm, 700 nm, 800 nm, 900 nm or 1000 nm, but it is not limited thereto. In accordance with some embodiments, the depth **D3** of the side recessed portion **108sr** may be different from the depth **D1** of the first recessed portion **108r-1** or the depth **D2** of the second through-hole **108v**. In accordance with some embodiments, the depth **D3** of the side recessed portion **108sr** may be greater than the depth **D1** of the first recessed portion **108r-1** or the depth **D2** of the second through-hole **108v**. With the above structural design of the side recessed portion **108sr**, the contact area between the third conductive pad **206** and the second insulating layer **108** at the edge can be increased. Similarly, the side recessed portion **108sr** having a stepped or wavy profile can also increase the contact area between the third conductive pad **206** and the second insulating layer **108**. In this way, the adhesion between the third conductive pad **206** and its underlying structure can be improved, thereby reducing the risk of peeling off of the third conductive pad **206**.

[0079] Refer to FIG. **10** and FIG. **11**. FIG. **10** is a top-view diagram of a connection structure **10C-3** in accordance with some embodiments of the present disclosure. FIG. **11** is a cross-sectional diagram of the connection structure **10C-3** corresponding to the section line **A4-B4** of FIG. **10** in accordance with some embodiments of the present disclosure.

[0080] In accordance with this embodiment, the connection structure **10C-3** may be electrically connected to a flexible printed circuit board (FPC) or a chip on film (COF) package, but it is not limited thereto. As shown in FIG. **10**, in accordance with some embodiments, a plurality of second conductive pads **204** may be disposed on the same first conductive pad **202**. Moreover, in a region corresponding to one second conductive pad **204**, the first insulating layer **106** may include a plurality of first through-holes **106v-1**, and the second insulating layer **108** may include at least one second through-hole **108v**, but it is not limited thereto. In accordance with this embodiment, the plurality of first through-holes **106v-1** may be arranged in an array, but it is not limited thereto.

[0081] As shown in FIG. **11**, the second conductive pad **204** may be disposed on the first insulating layer **106** and electrically connected to the first conductive pad **202** through the first through-hole **106v-1**. Furthermore, the first conductive pad **202** may include at least one contact portion **CT-1**, and the second conductive pad **204** may be in contact with the contact portion **CT-1** through the first through-hole **106v-1**. Moreover, the second insulating layer **108** may include a first recessed portion **108r-1**, and in the normal direction **Z** of the substrate **102**, the first recessed portion **108r-1** may overlap the first through-hole **106v-1**. The third conductive pad **206** may extend on the surface **108s-1** of the first recessed portion **108r-1**.

[0082] Next, refer to FIG. **12**, which is a top-view diagram of a connection structure **10C-4** in accordance with some embodiments of the present disclosure. As shown in FIG. **12**, a plurality of second conductive pads **204** may be disposed on the same first conductive pad **202**. In a region corresponding to one second conductive pad **204**, in addition to the first through-hole **106v-1** and



the third through-hole **106v-2**, the first insulating layer **106** may further include the first through-hole **106v-1'** and the third through-hole **106v-2'**, and the second insulating layer **108** may include the second through-hole **108v** and a second through-hole **108v'**. In accordance with this embodiment, in the first direction X, the second through-hole **108v** may be located between the first through-hole **106v-1** and the third through-hole **106v-2**, and another second through-hole **108v'** may be located between the first through-hole **106v-1'** and the third through-hole **106v-2'**. In accordance with this embodiment, in the second direction X, a minimum distance DA between the first through-hole **106v-1** and the first through-hole **106v-1'** may be different from a minimum distance DB between the second through-hole **108v** and the second through-hole **108v'**. In accordance with this embodiment, in the second direction X, the minimum distance DA between the first through-hole **106v-1** and the first through-hole **106v-1'** may be greater than the minimum distance DB between the second through-hole **108v** and the second through-hole **108v'**.

[0083] To summarize the above, in accordance with the embodiments of the present disclosure, the provided connection structure includes the conductive pad extending in the recessed structure, thereby increasing the contact area between the conductive pad and the underlying structure. The adhesion between the conductive pad and the underlying structure can be improved. The risk of cracks or peeling off of the conductive pad, or even peeling of components from the substrate can be reduced, thereby improving the reliability of the electronic device.

[0084] Although some embodiments of the present disclosure and their advantages have been described in detail, it should be understood that various changes, substitutions and alterations can be made herein without departing from the spirit and scope of the disclosure as defined by the appended claims. The features of the various embodiments can be used in any combination as long as they do not depart from the spirit and scope of the present disclosure. Moreover, the scope of the present application is not intended to be limited to the particular embodiments of the process, machine, manufacture, composition of matter, means, methods and steps described in the specification. As one of ordinary skill in the art will readily appreciate from the present disclosure, processes, machines, manufacture, compositions of matter, means, methods, or steps, presently existing or later to be developed, that perform substantially the same function or achieve substantially the same result as the corresponding embodiments described herein may be utilized according to the present disclosure. Accordingly, the appended claims are intended to include within their scope such processes, machines, manufacture, compositions of matter, means, methods or steps. In addition, each claim constitutes an individual embodiment, and the claimed scope of the present disclosure includes the combinations of the claims and embodiments. The scope of protection of present disclosure is subject to the definition of the scope of the appended claims. Any embodiment or claim of the present disclosure does not need to meet all the purposes, advantages, and features disclosed in the present disclosure.

## Claims

1. A connection structure, comprising: a first conductive pad; a first insulating layer disposed on the first conductive pad and comprising a first through-hole exposing a first portion of the first conductive pad and another first through-hole exposing another first portion of the first conductive pad; a second conductive pad disposed on the first insulating layer and electrically connected to the first conductive pad through the first through-hole and the another first through-hole; and a second insulating layer disposed on the second conductive pad and comprising a plurality of second through-holes, wherein the plurality of second through-holes expose a plurality of second portions of the second conductive pad, wherein in a top view, the plurality of second through-holes are disposed between the first through-hole and the another first through-hole.
2. The connection structure as claimed in claim 1, wherein a total area of the plurality of second portions is greater than a total area of the first portion and the another first portion.

3. The connection structure as claimed in claim 1, further comprising a third conductive pad disposed on the second insulating layer and electrically connected to the second conductive pad through the plurality of second through-holes.

4. The connection structure as claimed in claim 1, wherein the first through-hole and the another first through-hole do not overlap the plurality of second through-holes.

5. The connection structure as claimed in claim 1, wherein the second conductive pad is in contact with the first conductive pad through the first portion and the another first portion.

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